## The Frequency Dependent Conductivity of Electron G lasses

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Results of DC and frequency dependent conductivity in the quantum limit, i.e.  $h! > k_B T$ , for a broad range of dopant concentrations in nom inally uncompensated, crystalline phosphorous doped silicon and am orphous niobium -silicon alloys are reported. These materials fall under the general category of disordered insulating systems, which are referred to as electron glasses. U sing m icrowave resonant cavities and quasi-optical millimeter wave spectroscopy we are able to study the frequency dependent response on the insulating side of the metal-insulator transition. We identify a quantum critical regime, a Ferm i glass regime and a Coulom b glass regime. Our phenomenological results lead to a phase diagram description, or taxonomy, of the electrodynamic response of electron glass system s.

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#### I. IN TRODUCTION

Disordered insulating systems have gamered much interest from theorists and experimentalists alike over m any years. A plethora of results exist on the low energy physics of these disordered insulating systems from DC conductivity experim ents, but it is only recently that investigations of the T ! 0 frequency dependent response have been perform ed even though theoretical predictions have existed for many years. We have measured the DC conductivity as well as the complex frequency dependent conductivity, the latter being measured in the quantum -lim it, i.e. h! >  $k_B T$  for a few di erent disordered insulating system s. M easurem ents were perform ed on materials that fall on the insulating side of the metal insulator transition (MII), with a major focus on the e ects of electron-electron interactions. Theoretical predictions concerning the charge transport in system swith carriers localized in the Anderson sense exist both for system s without electron-electron interactions, these m aterials being referred to as Ferm iglasses<sup>1</sup>, as well as for system s that include the e ects of the C oulom b interaction, these materials being referred to as Coulomb glasses $^2$  . The majority dopant concentration of doped crystalline sem iconductors and am orphous m etal-sem iconductor alloys can easily be varied using standard sem iconductor growth techniques, and hence these materials provide a perfect playground to study the low energy electrodynam ics of localized charge carriers.

We focus our investigation on a broad region of phase space from close the the quantum critical point, i.e. the critical dopant concentration at which the M IT occurs,  $x_c$ , to deep within the insulating regime. Recent work on the AC conductivity of SiB<sup>3</sup> and SiP<sup>4</sup> have shown a crossover from the Ferm iglass to the C oulom b glass-like behavior qualitatively consistent with the theoretical expectations, but in all cases, the crossover ism uch sharper than predicted by theory. There exist two relevant energy scales in this problem. The rst is the C oulom b

interaction energy, U, which E fros and Shklovskii (ES) predicted determ ines the crossover energy between characteristic Fermiglass and Coulomb glass-like behavior<sup>2</sup>. An important result of the interactions is a depletion in the density of states of the charge carriers about the Ferm i level term ed a Coulom b gap . In a recent result, Lee et al.<sup>3</sup> claim from their measurements on SiB that the crossover energy scale is determ ined by the C oulom b gap width, , as opposed to the theoretically predicted C oulom b interaction energy, U . A rgum ents based on the concentration dependence of these two parameters obtained from measurements over a broad range of dopant concentrations in another canonical electron glass system, Sip, have recently been published by us casting doubt on this interpretation<sup>4</sup>. This highlights the usefulness and importance of investigating a wide range of m a prity dopant concentrations to fully understand these disordered insulating system s.

The primary goals of this work then are to present new data and to draw on results of previous work on other electron glass system  $s^{4}$  to look at the insulating side of the M II using AC conductivity data and a broad range of dopant concentrations in order to com e up with a phenom enologically supported phase diagram outlining the general classi cation scheme for the electrodynam ic response of electron glasses. DC conductivity data are presented as well and a side by side com parison of the AC and DC data provides for unique insight. Furtherm ore the AC data allows for a detailed com parison of the electron glass regime with theoretical predictions. We nd that some of the predicted features are observed, such as the frequency dependent conductivity power laws. In fact it is these powers that provide the taxonom ic information in the phase diagram to be presented herein. We also note discrepancies that arise in all the reported m easurem ents, such as the sharper than predicted crossovers from Ferm iglass to Coulom b glass behavior.

## II. BACKGROUND

## A.The M IT as a Quantum Phase Transition

The metal insulator transition is an archetypical quantum phase transition (QPT). The insulating portion of phase space associated with Ferm i glass and Coulom b glass behavior borders the quantum critical regime. The quantum critical region of phase space is that region where quantum mechanical elects due to being in proximity to the zero temperature quantum critical point manifest them selves even at nite temperatures or frequencies. Speci cally the electrodynamic response in a disordered electronic system, such as the lightly doped insulating sem iconductors studied in this work, should smoothly transform from Ferm i glass or C oulom b glasslike behavior into the appropriate quantum critical dynamic response as the dopant concentration is tuned and the M IT is approached.

For the M IT, the dopant concentration which is directly related to the charge carrier concentration, x, is typically the tuning param eter that determ ines whether at zero temperature the material is a metal, i.e. has a nite DC conductivity, or an insulator, i.e. the DC conductivity is zero. There exists necessarily then a critical concentration,  $x_c$ , at which the phase transition occurs thereby de ning a boundary between insulating and m etallic ground states. The disorder induced m etal-insulator transition and the dynam ical behavior near the critical point has been extensively theoretically studied over the past years both with and without electron-electron interactions<sup>7{10</sup>}. A thorough review has been written by Belitz and K irkpatrick<sup>11</sup>.

The condition for observing quantum critical behavior versus electron glass-like behavior on the insulating side of the M II is determined by the relative size of certain characteristic length scales. The characteristic thermal length scale is

$$r_{\rm T} / (k_{\rm B} T)^{1=z}$$
 (1)

and the frequency dependent length scale is

$$'_{!}$$
 / (h!) <sup>1=z</sup> (2)

where z is the dynam ical scaling exponent. These lengths are term ed "dephasing" lengths by Sondhi et al<sup>12</sup>. The localization length, a measure of how far the electronic wavefunction extends, is the other important length scale. It diverges as the transition is approached and can be written in term s of concentration as

where is the localization length exponent.

At nite temperature or frequency an intermediate regime exists between the metallic and insulating regimes that displays quantum critical (QC) behavior as shown

in Figure 1. In the QC regime the localization length is greater than the dephasing length scales,  $'_{T;!}$  < At the crossover from QC to the insulating regime this can be thought of heuristically as the electron scattering within a length scale that is shorter than the width of the wavefunction envelope that de neshow localized that electron is. In other words the electron can undergo scattering akin to norm altransport before "realizing" that it is localized. On the metallic side, the relevant length scale is commonly taken to be the screening length. In the opposite limit,  $< \sum_{T_{ij}}$  the system exhibits metallic or insulating behavior. For instance in the insulating regime, the material will display the appropriate hopping conduction consistent with the DC conductivity or the photon assisted frequency dependent conductivity. A schematic representation of the phase diagram showing the regime boundaries is shown in Figure 1.

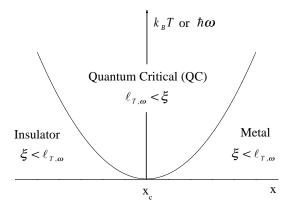


FIG.1. A schematic of the crossover diagram close to a quantum critical point showing the regime boundaries between quantum critical, m etallic and insulating behavior. The horizontal axis represents increasing concentration and the vertical axis represents either the tem perature or frequency energy scale. The crossover from QC to either m etallic or insulating behavior is determ ined by when the length scales are equivalent, i.e.  $Y_{\rm T,l}$ .

From equations (1), (2) and (3) we can determ ine a functional form, in terms of concentration, for the crossover between the QC and the metallic or insulating regimes by setting the dephasing length equal to the relevant length scale,  $Y_{r,!}$ . In so doing we nd

In this work the approach to criticality from the insulating side of the M II for two types of disordered insulators, SiP and NbSi, will be compared and discussed.

# B.DC Variable Range Hopping and the Coulom b Gap

M ott rst noted that at low tem peratures in a lightly doped disordered sem iconductor a form of DC conduction unique from nearest-neighbor hopping would occur<sup>13</sup>. It is commonly referred to as variable range hopping (VRH). M ott's derivation did not include electronelectron interactions and thus M ott-type hopping describes the variable range hopping m echanism in a noninteracting Ferm iglass<sup>1</sup>. In M ott's theory:

$$_{dc} / \exp[((T_0 = T)^{1 = (d+1)}]$$
 (5)

where d is the e ective spatial dimension for the hopping electrons. The characteristic M ott tem perature is given by

$$T_0 = = k_B N_0^{d}$$
: (6)

It is the characteristic energy scale of the level spacing in a volum e d, and dependent on the density of states  $(D \circ S), N_0$ . Here is a constant of order one.

The above derivation was based on the assumption of an approximately constant density of states near the Ferm i level, but as pointed out by Pollak<sup>14</sup> and Ambegaokar<sup>15</sup>, this assumption is invalid when correlation e ects are included. Upon including electronelectron interactions one nds that the Coulom bic repulsion is responsible for opening up a gap at the Ferm i energy, and that the functional form for the DC conductivity takes on an alternate tem perature dependence. This gap, term ed the Coulom b gap by E fros and Shklovskii<sup>16</sup> is given by

$$= \frac{e^{3}N_{0}^{1=2}}{n_{1}^{3=2}};$$
(7)

where " $_1$  is the full dielectric constant. The C oulom b gap is a "soft" gap in the density of states near the Ferm i level created by the C oulom b interaction between localized electrons. (The term soft is used because the density of states vanishes only at the Ferm i energy.)

E fros and Shklovskii followed M ott's derivation for the DC tem perature dependent VRH conductivity, but instead of using a constant density of states around the Ferm i level, they incorporated the Coulomb gap and therefore necessarily took correlation e ects into account. The appellation Coulomb glass describes an electron glass system which incorporates Coulom bic interactions. In so doing ES found the following form for the DC tem – perature dependent VRH conductivity

$$_{\rm dc} / \exp[((T_0^0 = T)^{1=2})]$$
 (8)

where the characteristic ES tem perature is given by

$$T_0^0 = 2 : 8e^2 = k_B "_1$$
 : (9)

The prefactor 2.8 is calculated from percolation threshold models  $^{17;18}$ . Note that the power in Eq. (8) is  $\frac{1}{2}$  in all dimensions unlike in M ott's form alism.

For the system swe are studying, any given sample with a particular dopant concentration may possibly exhibit m one than one type of behavior. Depending on the energies at which one is probing the system one might observe behavior consistent with Fermiglass, Coulomb glass or QC-like behavior. Therefore, by investigating a broad range of frequency or temperature space, our experimentalwindow might be broad enough to see crossovers from one type of behavior to another.

The most indicative piece of experimental evidence that most authors cite as to whether the materials being studied are Fermiglasses exhibiting Mott VRH or Coulom b glasses exhibiting ESVRH is the DC conductivity. The vicissitudes of using this experimental data to claim a material is a Coulomb or Fermi glass lie in the fact that only below a certain temperature does a m aterial enter the VRH regime, whereas above this cuto tem perature other form s of activated hopping occur. Thus only a small portion of low temperature data will show any sem blance of VRH behavior, and in three dim ensions, a sm all section of tem perature dependent data may tapower law of  $\frac{1}{2}$  or  $\frac{1}{4}$  alm ost equally as well making it di cult to say with any certainty which mechanism of charge excitation is occurring. M easurem ents of the T ! 0 K frequency dependent conductivity then allows for new insight into the M II and the electrodynam ics of electron glasses. M easurements of the DC conductivity on the same samples as those on which the AC conductivity measurements were taken o ers a consistency check with previous investigations and allows for comparison of salient features.

## C.AC Photon-assisted H opping

M ott proposed a form for the T = 0 K photon assisted frequency dependent hopping conductivity for the case of non-interacting electrons based on the theory of resonant absorption using a simple one electron m odel of a disordered system, com m only referred to as the pair approximation<sup>1;19</sup>. The resulting real part of the AC conductivity, 1, in M ott's form alism is as follow s:

$$_{1} = e^{2} N_{0}^{2} {}^{5} h!^{2} [ln (2I_{0}=h!)]^{4}:$$
 (10)

Here is some constant close to one, and  $I_0$  is the prefactor of the overlap integral (commonly taken to be the Bohr energy of the dopant^{20}). Most notably we see that in Mott's form alism, the conductivity has an approximately quadratic frequency dependence, plus logarithm ic corrections.

By taking into account the mean C oulom b interaction between two sites forming a resonant pair

$$U(r_1) = e^2 = r_1 r_1$$
 (11)

where  $r_! = [ln (2l_0=h!)]$  is the most probable hop distance between pairs, E fros and Shk lovskiiderived the real part of the AC conductivity to be:

$$_{1} = e^{2} N_{0}^{2} {}^{5} ! [ln (2I_{0}=h!)]^{4} [h! + U (r_{w})]:$$
(12)

This form ula takes on a di erent frequency dependence in two limiting cases. In the case where the photon energy is greater than the Coulomb interaction energy, h! > U (r<sub>1</sub>), one retrieves the same approximately quadratic frequency dependence in M ott's form ula (10), and here the Coulomb glass is indistinguishable from the Ferm i glass in so far as the frequency dependent conductivity is concerned. For the alternate case i.e. when the photon energy is smaller than the Coulomb interaction energy, h! < U (r<sub>1</sub>), the conductivity of a Coulomb glass will show an approximately linear dependence on frequency, plus logarithm is corrections. M odel data for this functional form is shown in Figure 2 showing that the crossover is predicted to occur overm any decades of frequency.

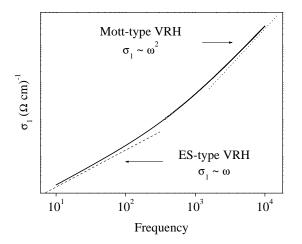


FIG.2. A schem atic of the crossover function from M ott to ES-type AC conduction set forth by E fros and Shklovskii and de ned in Eq. (12) displayed on logarithm ic axes. The vertical axis is conductivity with arbitrary units and the horizontal axis has been set to show the crossover occurring in the m illim eter-wave range if the units are taken to be G H z. The dashed and dotted straight lines show the asym ptotically approached linear and quadratic dependencies of the crossover function.

As for the DC case, one further ram i cation of including electron-electron interactions is the depletion of the single particle density of states around the Ferm i level, i.e. the Coulomb G ap . In the special case when  $> U(r_{\rm !}) > h!$  E fros and Shkbovskii calculated the real part of the frequency dependent conductivity and obtained

$$_{1} \quad \frac{1}{10} \frac{! "_{1}}{\ln (2I_{0}=h!)}; \tag{13}$$

so that the dependence is slightly super-linear, assuming a frequency-independent dielectric constant, and independent of the localization length, which would indicate a very weak concentration dependence.

Thus, by using the frequency dependent conductivity one has a unique m eans to determ ine the relevant energy scales between interacting and non-interacting behavior. Several recent experiments<sup>3;21</sup> have shown a possible crossover from interacting to non-interacting behavior in the same material. Some of this experimental data has been interpreted to indicate that the C oulom b gap width energy scale, certainly another germ ane energy scale in the system, sets the crossover energy scale in opposition to the theoretical prediction that the Coulomb interaction energy dictates the crossover from Fermi glass to Coulomb glass-like behavior. These arguments though were based on measurements covering a limited range of dopant concentrations. Therefore the frequency dependent conductivity measured in the low energy excitation range for a broad range of concentrations can provide useful inform ation about the crossover energy scale, be it the Coulomb gap width or the Coulomb interaction energy.

#### III.EXPERIMENTS

Experim ents were perform ed on nom inally uncom pensated phosphorous doped silicon samples that were cut from a boule grown by Recticon Enterprises Inc. to a speci cation of 5 cm in diameter with a majority dopant gradient along the axis. This boule, grown using the Czochralskim ethod, was subsequently sliced into 1 mmthick wafers. By the nature of the C zochralskim ethod for growing a crystal, there is an inherent gradient in the maprity dopant concentration along the axis of the boule. A greater range of variation in this dopant concentration along the axis of the boule can be achieved by continuously adding progressively more dopant of choice, in our case phosphorous, to the molten silicon as the ingot is being drawn from the liquid mixture. As summarized in the rst column in Table I, we obtained samples spanning a majority dopant concentration from 1:37  $10^{18}$  cm  $^{3}$ to 2**:**98  $10^{18}$  cm <sup>3</sup>. The m iddle column lists the ratios of the sam ples as a percentage of the dopant concentration in each sample relative to the critical concentration at which the M II occurs,  $x_c = 3.5 \quad 10^{18}$  cm<sup>-3</sup>. The nalcolum n lists the room tem perature resistivity of each sample in ( om ) measured using an ADE 6035 resistivity gauge, which can be directly related to the dopant concentration, knowing the ilk of majority dopant in the silicon via a phenom enological scale set forth by Thurber  $et al^{22}$ .

P reviously reported results from another electron glass system, namely am orphous NbSi, will be drawn upon when discussing the general features of the electron glass phase diagram. These sam ples were created by sputtering onto sapphire substrates, and both millim eter-wave and DC conductivity measurements were performed,

x 10 <sup>18</sup> cm <sup>3</sup>	Percent of Critical: $\frac{x}{x_c}$	<sub>dc</sub> (300 K ) ( cm )
2.98	85%	0.0133
2.66	76%	0.0142
2.42	69%	0.0150
2.17	62%	0.0159
1.96	56%	0.0168
1.74	50%	0.0179
1.56	45%	0.0189
1.37	39%	0.0202

TABLE I. The material parameters for eight SiP samples obtained from a boule grown by Recticon Enterprises Inc. The left hand column lists the concentration of the majority dopant phosphorous in each sample. The middle column lists the ratio as a percentage of the dopant concentration in each sample relative to the critical concentration of the M IT, namely  $x_{\rm c}=3.5~10^{18}$  cm $^3$ . The right hand column lists the value of the room temperature DC resistivity value for each sample.

analogous to those done on SiP.M ore detailed sample speci cations for these am orphous m etal-sem iconductor alloys and experimental results can be found in the literature<sup>5</sup>.

It is important to perform DC conductivity measurements on the same SiP samples for which the AC measurements were done for a number of reasons. First, the DC measurements o er a consistency check to previous experimental results. A lso, one can compare important parameters, such as the localization length, as determined separately from the DC and AC data. These measurements also provided a low temperature value of the DC conductivity to which one can norm alize the realpart of the microwave resonant cavity complex conductivity. For example, at approximately 25 K the realpart of the resonant cavities, namely 35 GH z and 60 GH z, should be dominated by the thermally driven charge transport mechanism that determines the DC conductivity.

DC conductivity m easurem ents were perform ed on the SiP samples using a standard four probe measurement technique from liquid <sup>4</sup>H e temperature up to approxim ately 100 K. Figure 3 shows data from three samples from 42K up to 20K.At the higher tem peratures shown in the main portion of the gure for the the 69 % sam ple, and also evident in the inset plot of the 56 % sam ple m easured up to approxim ately 200 K, the curves show a rounding o indicative of a conduction process consistent with a Boltzmann type activation. A loo evident in the middle of the displayed temperature range is a kink in each of the sample's data indicative of a crossover from one form of activation to another. V isually the crossover tem perature,  $T_x$ , for each of the sam ples decreases with increasing dopant concentration. This would be consistent with a crossover from Mott to ES-type VRH, but other experim ental evidence, to be discussed presently,

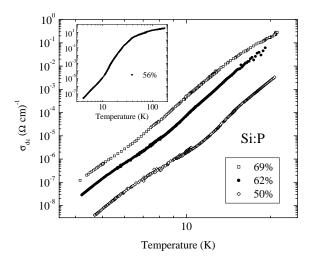


FIG.3. The DC conductivity versus tem perature on logarithm ic scales for a series of SiP samples. At high tem peratures one can notice a crossover to activated Boltzm ann-type behavior. A lso noticeable is a crossover tem perature,  $T_x$ , in the middle of the displayed tem perature range that decreases with increasing dopant concentration.

indicates that M ott and ES-type VRH theories do not correctly describe the upper and lower pieces of the DC conductivity data shown in Figure 3.

Figure 4 shows the measured DC conductivity from the 62% sample both prior to and after etching in a 4% HF + 96% HNO3 solution for 20 m inutes. Unless otherwise specied all AC and DC conductivity measurem ents reported herein were perform ed on etched SiP samples. As rst pointed out by O otuka et al.23, a crystalline sem iconductor sample sliced from a boule using a diam ond saw will create surface defects. As indicated in the gure, at low temperatures the surface defects seem to provide a channel for conduction with less resistance than the surface defect-free bulk sam ple, increasing the overall measured bulk conductivity. DC conductivity m easurem ents on sam ples etched for 20 m inutes and 2 hours showed no di erence indicating that 20 m inutes of etching su ced to rem edy the e ects of surface defects, consistent with the ndings of O otuka et al.23. Regardless of the presence of surface defects altering the relative m agnitude of the measured bulk conductivity, the kink in the data indicating a crossover tem perature,  $T_x$ , is still. clearly present in both sets of data.

Both components of the complex frequency dependent conductivity were determined from transmission measurements using a technique called quasi-optical spectroscopy. Quasi-optical spectroscopy has been utilized and partially developed by our research group to investigate the electrodynamic response of materials in the millimeter to sub-millimeter wave range (i.e. the terrahertz frequency regime)<sup>24;25</sup>. Historically the millimeter and sub-millimeter wave spectral range, higher in fre-

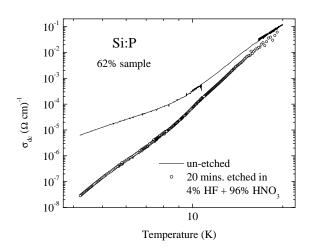


FIG.4. The DC conductivity versus tem perature on a logarithm ic scale for the 62% SiP sample both prior to and after etching the sample.

quency than standard radio-frequency (RF) techniques and lower in frequency than common infrared (IR) techniques, has not been studied, leaving a gap in the know ledge of the optical response of physically intriguing systems. This spectral range corresponds with the range of energies wherein electron-electron interactions are predicted to occur in disordered systems. A lso experiments in this spectral range can easily be done in the quantum limit, h! >  $k_{\rm B}$ T, with standard cryogenic techniques, i.e. a pumped liquid  $^4{\rm H}$  e optical cryostat (recall that 1 K ' 20 G H z).

The quasi-optical transmission measurement technique takes advantage of broadband sources of coherent electrom agnetic radiation known as Backward W ave O scillators (BW 0). The frequency of the output radiation from these sources can be swept by adjusting the applied potential. The resulting output power spectrum is extremely reproducible Recording the power received at the detector for 1) the sample and then 2) a blank or free space, and taking their ratio provides the transmission data as a function of frequency. The striking feature of the transm ission spectra is the periodically spaced peaks known as Fabry-Perot resonances which occur whenever the thickness of the sample is equal to an integer number of half wavelengths inside of the sample. The transmission can be recorded and the resonant peak's center frequencies and heights can be determined. From these measured param eters one can directly determ ine the real and in aginary components of the complex conductivity.

Below a certain temperature, it was found that the Fabry-Perot resonance transmission traces did not change. This necessarily means that below some temperature the real and in aginary components of the complex conductivity, become temperature independent. At low temperatures therm alcontractions, which can a ect both the peak heights and center frequencies become negligible as well. Figure 5 shows this trend by plotting the conductivity of the 69% sample versus temperature for various constant frequencies with the DC conductivity. It is clear that at high temperatures the AC conductivity curves approach and follow the temperature dependent DC conductivity, and the greater the frequency of a particular curve, the greater the temperature at which this occurs. It is also clear that the iso-frequency curves do indeed atten out at low temperatures, indicating that the T = 0 K photon-assisted hopping behavior is being observed. All of the other sam ples showed a similar attening out of the AC conductivity at low temperatures.

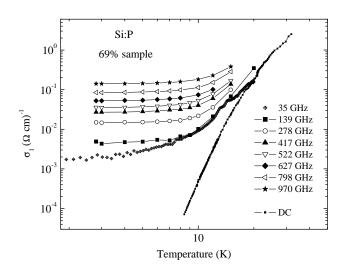


FIG.5. Both the DC conductivity and the real component of the complex conductivity at various constant frequencies versus temperature on logarithm ic scales for the 69% sample.

U sing DC data alone, evidence of the e ects of electron-electron interactions, namely a crossover from M ott to ES type VRH is questionable at best. The range of tem perature across which the various conduction processes m ight be occurring are m inim al and it is di cult to have con dence that a tto M ott-type T <sup>1=4</sup> behavior or ES-type T <sup>1=2</sup> behavior is correct. The distinguishing features of an interacting versus a non-interacting disordered system are much easier to tell apart when investigating the frequency dependent conductivity though. Speci cally, linear and quadratic power law are clearly discemable and evidence for such a crossover in the frequency dependent conductivity spectrum is clearly seen as shown in Figures 6 and 7.

## IV . A N A LY SIS A N D R E SU LT S

## A.DC Conductivity

M uch of the story that the DC conductivity can tell is sum m arized in Figure 8 which shows the DC conductivity of the 50% Sip sample. The data in the upper

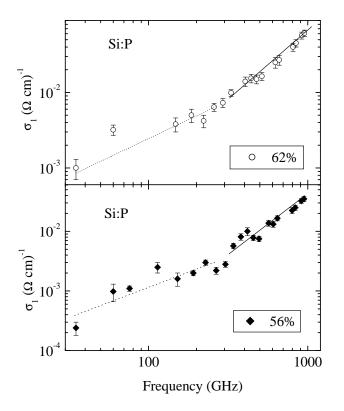


FIG.6. The measured 2.8 K value of the real part of the complex frequency dependent conductivity for the SiP 62% and 56% samples plotted versus frequency on logarithm ic axes displaying a crossover in the type of conduction mechanism. The dashed line is a t to the lower portion of the data and follows a nearly linear power law. The solid line through the upper portion of the data is a t of that data and follows a nearly quadratic power law.

panel is plotted on a T  $^{1=4}$  axis in order to assist visual recognition of M ott type VRH behavior. The lower panel shows the sample data plotted on a T  $^{1=2}$  axis in an attempt to elucidate any region of data that might be following ES type VRH behavior. W hen plotted on any inverse tem perature scale, the left hand side represents the high tem perature region, and it is this higher tem perature region, up to approxim ately 25 K, that has been t to a linear function in the upper panel. However, closer inspection of Figure 8 reveals that in the upper panel, although the higher tem perature data has been tted to T  $^{\rm 1=4}$  behavior, the lower portion seems to be linear as well indicating a possible T  $^{1=4}$  dependence as well on this sem i-log plot. In the lower panel of Figure 8, the lower tem perature data is tted to a linear function, possibly indicating that in this region, i.e. below T<sub>x</sub> 12 K, the data m ight well be described as following ES type behavior. As in the upper panel, the other region of data, in this case the higher tem perature

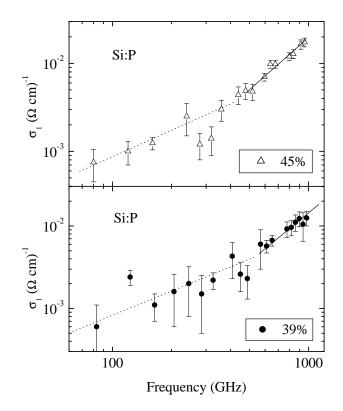


FIG.7. The measured 2.8 K value of the real part of the complex frequency dependent conductivity for the SiP 45% and 39% samples plotted versus frequency on logarithm ic axes displaying a crossover in the type of conduction mechanism. The dashed line is a t to the lower portion of the data and follows a nearly linear power law. The solid line through the upper portion of the data is a t of that data and follows a nearly quadratic power law.

data, shows a som ewhat linear dependence at least over a nite range of tem perature.

That the upper and lower portions of the data seem linear on either scale sum marizes the vicissitudes of trying to determ ine M ott or ES type behavior from the DC data alone. From Figure 8 one sees that the SiP 50% sample has a crossover tem perature of approxim ately 12 K, whereupon the DC conductivity begins to follow a di erent dependence. It is unclear if this tem perature sets the energy scale at which a crossover from M ott to ES type VRH occurs, but nevertheless it is clearly an im portant energy scale in this m odel disordered system.

Further analysis shows that thing the high tem perature and low tem perature portions of  $_{\rm dc}$  respectively to M ott and ES-type functional forms, across our experimentally accessible tem perature range, is incorrect. The characteristic M ott tem peratures, T<sub>0</sub>, determined for our SiP samples is of the order  $10^7$  K, a ridiculously large value. The ES characteristic tem peratures, T<sub>0</sub><sup>0</sup>, determined for our

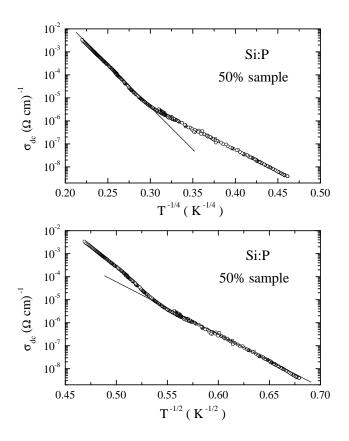


FIG.8. The DC conductivity for the 50% SiP sample plotted versus T  $^{1=4}$  in the upper panel and plotted versus T  $^{1=2}$  in the lower panel.

m ined by tting the lower temperature data are more reasonable but still extrem ely large, of the order  $10^3$  K . C om pared to the characteristic M ott and ES temperatures m easured by D ai et al.<sup>26</sup> and H omung et al.<sup>27</sup>, our values seem extrem ely high and unphysical, even though their m aterials were of a di erent com position, or fell in a di erent range of dopant concentrations.

Further evidence that the Mott and ES functional form s are inappropriate can be gleaned from analysis of the localization lengths from the characteristic temperatures. Using the relationship for the ES characteristic temperature, i.e. Eq. 9 and the measured values of  $T_{0}^{0}$ , the localization lengths for the various SiP sam – ples within our doping range com e out to be less than 2 nm, not an unreasonable length scale as the interatom ic spacing in the diam ond structure lattice of Si is 2.35 A, but an order of magnitude smaller than the 20 nm found from analyzing the AC conductivity data, to be presented in the following section. With an appropriate estim ate of the non interacting density of states N $_0$  (E $_{\rm F}$ ), an estimate of the localization length can also be determined from  $T_0$ . For example the 62% sample,  $10^{\circ}$  K , estimating N  $_{0}$  (E  $_{\rm F}$  ) to be the with a  $T_0 = 39$ ratio of the dopant atom ic density  $x = 2.173 \quad 10^{2} 4 \text{ m}^{-3}$ 

to an appropriate bandwidth, 0:1 eV, gives a localization length of approximately 6 A, a factor of 4 smaller than the one determ ined from  $T_0^0$ . That the localization lengths do not agree gives further evidence that 1) either our assumptions of what regions of the DC conductivity correspond to M ott or ES type VRH are incorrect or that 2) deep in the insulating regime behavior di erent than that predicted for canonical C oulom b and Ferm i glasses exists.

The form er case m ay well be true, (although evidence from the AC conductivity m easurem ents seem to indicate otherwise), and these issues will be discussed presently, but rst the latter issue shall be addressed. In fact such a prediction that deep in the insulating regime an alternate m ethod of charge transfer should exist is exactly what H ornung et al.<sup>27</sup> claim to have observed in their DC conductivity m easurem ents of SiP. Am ong other ndings, these authors claim that below a majority dopant concentration of 2:78  $10^{18}$  cm  $^3$ , (recall that  $x_c = 3.52 \quad 10^{18}$  cm  $^3$ ) the conductivity w as better described by an activation process with an activation energy  $E_2$  which was interpreted as a "hard" H ubbard gap.

Inspection of the 1:80  $10^{18}$  cm  $^{3}$  and 2:40  $10^{18}$  cm  $^{3}$ dopant concentration data presented in literature<sup>27</sup>, which were analyzed as an activation process, show that the data spanned a very small tem perature range. Our 69% sample corresponds to a dopant concentration very sim ilar to the 2:40 10<sup>18</sup> cm <sup>3</sup> dopant concentration sam ple in Ref. 29. Our DC conductivity results extended to 4.2 K. As indicated in Figure 3 a kink in the curve is clearly evident, which occurs at or som ewhat below the lowest temperature indicated in the work from Hornung et al.<sup>27</sup>. The change in functional form that we observe is inconsistent with the presence of a hard gap which would result in a single activated process as the conduction mechanism. As we will show below, further evidence for the absence of a hard gap com es from the fact that we observe appreciable AC conductivity at frequency scales wellbelow that of the purported gap energy.

#### B.AC Transport and Polarizability: The Crossover

Some of the most stunning and germ ane results from these investigations of electron-electron interactions in disordered systems are best sum marized visually in Figure 9 in which the measured real part of the complex conductivity for the 69% and 50% samples are displayed as a function of frequency. The solid lines are linear and quadratic ts to the lower frequency and higher frequency data respectively, qualitatively displaying the expected behavior for a crossover from a C oulom b glass to a Ferm i glass. The overlayed dotted lines are ts to the data using Eq. (12) and clearly this form ula provides only a rough guide. The t was made by forcing the linear portion to pass through the origin as well as the low frequency data and leaving the prefactor of the quadratic portion as a free parameter. The crossover between linear and quadratic behavior is much more abrupt than the ES function predicts and is observed over our entire doping range. Such behavior was previously observed in an analogous disordered sem iconductor system, SiB, for two very closely spaced doping levels near the M IT<sup>3</sup>.

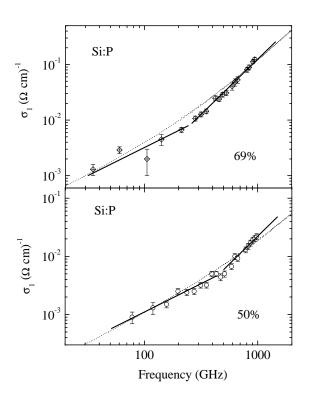


FIG.9. The measured real part of the complex conductivity for the 69% and 50% SiP samples as a function of frequency. The solid lines are linear and quadratic ts to the lower frequency and higher frequency data respectively qualitatively displaying the expected behavior for a crossover from a C culom b glass to a Ferm iglass. The overlayed dotted lines are ts to the data using Eq. (12).

The sharpness of the crossover is interesting in its own right and deserves further investigation as we do not here propose an explanation. This crossover in the realpart of the complex conductivity was observed across our entire dopant concentration range except for samples very close the M IT, where the crossover presumably occurs below our experimental frequency range. The experimentally determined crossover frequency,  $!_c$ , plotted versus concentration in a functional form  $1 \quad \frac{x}{x_c}$  is summarized in Figure 10.

The functional form in Figure 10, namely a power law in 1  $\frac{x}{x_c}$ , is chosen because both the localization length, , and the dielectric susceptibility of a sam plenear the M II, namely 4 = "1 "si, are either predicted to or have been experimentally shown to follow such a form. Fitting the crossover frequency to such a functional form we nd

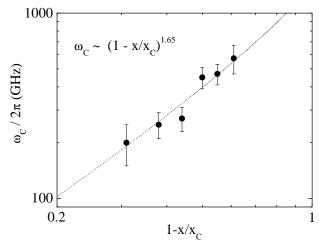


FIG.10. The experimentally determined crossover frequencies for the various SiP samples. The data is plotted against concentration in a functional form  $1 \frac{x}{x_c}$ . We nd = 1:65.

that  $!_c$  is proportional to  $1 \frac{x}{x_c}$  where = 1.65. By comparing the concentration dependencies of the relevant energy scales to this experimentally determined power we will show that the C oulom b interaction energy determines the crossover.

Recall that two energy scales have been set forth as being the energy scale at which the crossover from Ferm i glass to Coulomb glass-like behavior is to occur. The original theoretical fram ework set forth by E fros and Shklovskif has the C oulom b interaction energy U as the im portant energy scale. The second relevant energy scale in these systems is the Coulomb gap width, . The evidence that the C oulom b gap is the pertinent energy scale of the system stems from an experiment performed by Lee et al.<sup>3</sup>. This report claim s that it is not a gap in the single particle density of states, but rather a "dressed" Coulom b gap in the multi-particle density of states that determ ines the critical energy scale. Their claim, for which there does exist a theoretical fram ework<sup>28</sup>, is that hopping phenom ena occur due to multi-particle processes or polaronic e ects, but that a Coulom b gap still form s in the density of states of these charge carrying entities. Nevertheless it is not unreasonable to believe that the dressed Coulomb gap should take a similar form to that of the ES single particle gap, Equation (7), as both are presum ably caused by the sam e long range C oulom b interaction.

The dielectric constant enters into m any of the germ ane form ulae describing the electrodynam ics of these disordered insulating systems. The e ects of screening and polarization becom e m ore and m ore relevant as the M IT is approached. Therefore it is of fundam ental im portance to develop a theory that self-consistently takes into account the e ects of the imaginary component of

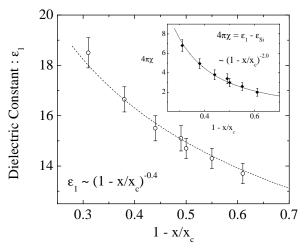


FIG.11. The T = 2.8 K full measured dielectric constant "1 for the various SiP samples are plotted versus 1  $\frac{x}{x_c}$ . The inset is that portion of the dielectric constant due to the disordered interacting system itself, 4 obtained by subtracting o the background dielectric constant "si (of the host material silicon) from the full dielectric constant "1. A clear divergence as a function of concentration is seen. These measurements are consistent with previous reports, and facilitate the analysis of the crossover energy scale.

the frequency dependent conductivity, i.e. the dielectric constant. As m entioned before, the immense advantage of our experimental techniques is the fact that we were able to separately measure both components of the complex conductivity. The full measured dielectric constant, as determined at T = 2.8 K, which is independent of frequency across our accessible frequency range (50 - 1000 G H z), is displayed in Figure 11. The inset shows that portion of the dielectric constant due to the disordered interacting system itself, which we refer to as the dielectric susceptibility of the disordered system, 4 , obtained by subtracting o the background dielectric constant "si (of the host material silicon) from the full dielectric constant "1.

M easurements of the concentration dependent divergence of the dielectric constant are not new but having independently determined the values for our samples at these frequency ranges allows formore accurate analysis of the crossover energy scales. As a measure of condence, when compared to previous experimental data on the dielectric susceptibility portion, namely 4 , of the full dielectric constant for SiP<sup>29</sup>, which was found to ta form  $\frac{x_0}{x}$  1, with = 1:15, we obtain from our data, when plotted and tted in a similar fashion, a power also very close to unity, namely 0.96. However, measurements of the full dielectric constant, "1, reported in the literature on SiB<sup>30</sup>, a disordered insulator analogous to SiP, were tted to a functional form of 1  $\frac{x}{x_0}$ ,

and the power was found to be  $^{0} = 0.71$ . We ob-

tain from our data, when plotted and tted in a simi-

lar fashion, a power for " $_1$  / 1  $\frac{x}{x_c}$ of  $^{0} =$ 0:38, which is almost a factor of 2 di erent. This is perhaps accounted for by the fact that the materials have di erent dopant material. One must be cautious when analyzing the full dielectric constant in this latter manner as is found som etim es in the literature because there is a constant additive term due to the background dielectric constant of the host m aterial Silicon "Si = 11:7 contained in the full dielectric constant  $"_1 = "_{Si} + 4$  , and only at dopant concentrations very close to critical does one obtain "1  $"_{\rm Si}$ . Our subsequent analysis of the 4 crossover energy between the non-interacting Ferm iglass behavior and the electron-electron interaction dependent behavior of the Coulomb glass state is carried out using the latter norm alized concentration functional form,

1  $\frac{x}{x_c}$ . It is therefore in portant to note here that as displayed in the inset of Figure 11, the dielectric susceptibility analyzed in thism anner is found to obey the power law dependence, 4 / 1  $\frac{x}{x_c}^2$ , which presumably become so the dominant power law dependence arbitrarily close to the M IT as the host material's "si becomes negligibly small. In fact such a trend can be seen in "1 in Figure 11, where at higher concentrations, namely the left-hand side of the gure, the slope tends to be steeper, as compared to the lower dopant concentrations on the right-hand side of the plot.

U tilizing the m easured values of the full dielectric constant for each sample one can now analyze the crossover energy. We mention brie y that in our analysis we parameterize ! c in terms of concentration. We acknow ledge that the crossover energy should not scale as a power law over the whole doping range, but in our limited range modelling shows this to be an acceptable parameterization. Now let us rst exam ine the C oulom b gap width . The experimental data shows that the crossover fre-

quency  $!_{c}$  is proportional to  $1 \frac{x}{x_{c}}$ where from our = 1:65, and the full dielectric constant " $_1$  / analysis  $\frac{x}{x}$ . Using these values and Eq. 7 one nds that the DOS goes as N  $_0$  / 1  $\frac{x}{x_c}^2$ . On the other hand the D O S can simply be estimated as N  $_{\rm 0}$ x=W ,ie. the dopant concentration divided by the bandwidth  ${\tt W}$  , which could only show the correct behavior stated above if the bandwidth were increasing faster than the dopant concentration itself. It is quite unlikely that the DOS could have a concentration dependence that would make this explanation consistent with the measurements, but one cannot entirely rule out that the resulting concentration dependence is inconsistent with the Coulomb gap width as the DOS's concentration dependence is di cult to ascertain and the arguments provided above simply provide a reasonable estim ate.

There is strong support how ever that the crossover en-

ergy is determ ined by the C oulom b interaction energy though. By setting the measured crossover energy scale equal to the C oulom b interaction energy we are able to determ ine both the magnitude of the localization length and the exponent with which it diverges as a function of concentration. U sing an appropriate pre-factor for the overlap integral<sup>20</sup>,  $I_0 = 10^{13}$  s<sup>-1</sup>, in the most probable hop distance term,  $r_! = [n (2I_0=h!)]$ , we ind a localization length dependence as shown in Figure 12.

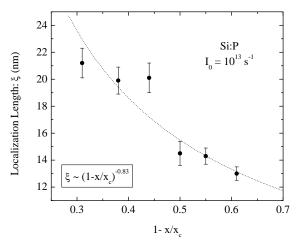


FIG. 12. Calculated localization length plotted versus  $1 \frac{x}{x_c}$  as determined from the measured crossover frequency energies. Our analysis entailed using an appropriate pre-factor for the overlap integral<sup>20</sup>,  $I_0 = 10^{13}$ s<sup>1</sup> in the most probable hop distance term,  $r_1 = [n (2I_0 = h!)]$ .

The localization length exponent as shown in the gure is close to unity, the value originally predicted by M cM illan in his scaling theory of the M IT  $^{10}$  , and the m agnitude of the localization length is reasonable. The choice of the prefactor for the overlap integralm ay vary, but due to the fact that it is located within a natural logarithm term, even an order of m agnitude variation greater or sm aller than 10<sup>13</sup> will result in a change of approxim ately a factor of two in the localization length. The consequent analysis for the localization length exponent, namely after changing  $I_0$  by an order of magnitude both greater and sm aller, still results in an exponent close to unity for both cases. It must be mentioned that some experimental results have indicated a localization length exponent closer to  $\frac{1}{2}$ , but these were found on the metallic side of the M II using the zero temperature conductivity<sup>29</sup>. These results strongly point towards the Coulom b interaction energy as being the energy scale at which the observed frequency dependent crossover from ES to M ott-like hopping conduction occurs.

Figure 13 o ers a sum mary of various experimental data on di erent types of disordered insulating systems, including our own, of measured DC and AC crossover energies versus the normalized concentration parameter,

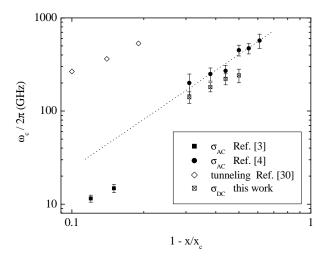


FIG.13. Sum m ary of various experimentally determined crossover energy scales determining the boundary between the interacting and non-interacting states of an electron glass system. The data represented by the open diam onds is adapted from tunnelling measurements<sup>30</sup> and the data represented by the full diam onds is adapted from AC conductivity network analyzer measurements performed in a dilution refrigerator<sup>3</sup>. B oth measurements were done on SiB, a disordered insulator analogous to SiP.0 ur measured crossover frequencies<sup>4</sup> are represented by the full circles and our experimentally determined crossover temperatures are converted to frequency and are represented by the crossed squares.

 $\frac{x}{x_c}$  . The crossover energy for the various exper-1 in ental techniques are converted to frequency and displayed in the gure as GHz. The data in the upper left of the gure displayed as open diam onds is the C oulom b gap width in the single particle DOS as determined by tunnelling m easurem ents in SiB<sup>30</sup>, a disordered insulator analogous to Sip.Although the Coulom b gap, speculated by Lee et al. to set the scale of the linear to quadratic crossover, was a sm aller re-norm alized or "dressed" one, on this plot the single particle gap sets an overall scale. One can see that the crossover energy is well inside the single particle Coulomb gap for all energies. The data in the lower left portion of the gure depicted by the full diam onds are crossover frequencies as determ ined by Lee et al. from AC conductivity measurements using a network analyzer and a dilution refrigerator in order to achieve quantum limit-like behavior on the same set of SiB samples as the above tunnelling data<sup>3</sup>. In their m easurem ents, a sharp crossover analogous to our own observations was seen. The solid circles in Figure 13 represent the crossover frequencies as determ ined from our frequency dependent conductivity m easurem ents on SiP.Our data extends the observed range of the sharp crossover deep into the insulating regim e as the SiB m easurements were closer to the critical concentration. The SiP and SiB data do not fallon the same line. This may be due to slight di erences in these various disordered

system s' dielectric constants or localization lengths. F inally the open crossed squares represent the crossover energies determ ined by us from our DC conductivity m easurem ents. A s can be seen the DC crossover data show a seem ingly one-to-one correspondence to the observed crossover energies with the AC data. This in itself is a curious result, as the subsequent analysis of the DC data indicated that the observed crossover was not consistent with a crossover from Ferm i glass M ott-like behavior to C oulom b glass E S-like behavior.

As a nalnote on the crossover data, recall that in the literature (see Ref. 29) one nds experim ental DC conductivity data analyzed to indicate that in Sip below a certain dopant concentration, approximately  $x=x_c =$ 80%, a "hard" Hubbard gap opens up. Having observed appreciable AC conductivity at frequencies below the purported hard gap energy, seems to rule out the possibility of a "hard" Hubbard gap, as the optical conductivity would be expected to drop precipitously to zero if such a gap were present. In fact it seems that the picture set forth by E fros and Shklovskii describing a crossover in the realpart of the complex conductivity from a linear to quadratic dependence on frequency due to the e ects of electron-electron interactions, seem s to hold from very close to the quantum critical regime to deep within the disordered insulating electron glass system at least qualitatively if not quantitatively. From the expected form of U (x), i.e. Eq. 11, and the reasonable behavior of the extracted , it seems likely that the crossover is governed by the C oulom b interaction strength of a resonant pair as predicted by E fros and Shklovskii, but the sharper than expected behavior still needs to be explained.

# C.AC Transport and Polarizability: The Coulom b $$\rm G$$ lass

Having established the fact that indeed a crossover in the real part of the frequency dependent com plex conductivity occurs across a broad range of dopant concentrations in an archetypicalm odel system of a disordered insulator, we wish to focus on the low energy limit of this electron glass system, i.e. the Coulomb glass. We will attempt to highlight successes and shortcomings of the theoretical predictions by drawing on the results of both the real and imaginary components of the complex conductivity of SiP and the previously reported results of another experim entally determ ined Coulom b glass, namely NbSi<sup>5</sup>. Comparing and contrasting the results of two Coulom b glasses, an am orphous highly doped m etal-sem iconductor alloy, NbSi, and a comparatively sparsely doped crystalline sem iconductor, Sip, evidence for a general phase diagram of the Coulom b glass and the quantum critical region is revealed relative to our experim entally accessible window .

Figures 14 and 15 show the low energy magnitudes of the real and imaginary components of the complex frequency dependent conductivity plotted against frequency

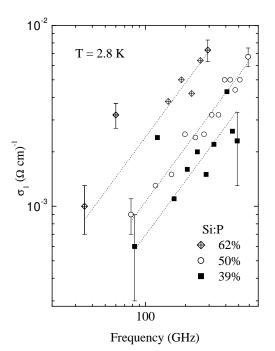


FIG.14. The low energy, linear in frequency portion of the real part of the com plex conductivity measured for three SiP samples plotted versus frequency. This data focuses on the C oulom b glass portion of electrodynamic response. The dashed lines are forced linear ts indicating self-consistency with the theory for a C oulom b glass, namely a linear frequency dependence and an increase in the magnitude of  $_1$ with increasing dopant concentration.

for a number of Sip samples. These gures focus on the low frequency C oulom b glass data from the m easurem ents of our experim entally accessible region of the optical conductivity. The dashed lines are linear ts to the data, highlighting two telltale characteristics of C oulom b glass-like behavior, namely a linear dependence of both components of the complex conductivity on frequency, and an increase in the magnitudes of both  $_1$  and  $_2$  with increasing dopant concentration. The error bars shown in Figure 14 are representative of all the data point's errorbars; they show a general trend of increasing at low er frequencies both due to the logarithm ic plot and the increasing di culty in measuring such low conductivities. By contrast the error bars are much sm aller and there is little scatter of the data points from the linear ts in Figure 15 because due to the inherent nature of an insulating system, the relative m agnitude of the im aginary com ponent is greater than the real component of the complex conductivity, and therefore falls in a range that can be m easured m ore accurately and precisely.

C loser inspection of Figure 15 will reveal that the  $_2$  data is linear across the entire measured spectral range, whereas the previous section clearly established a

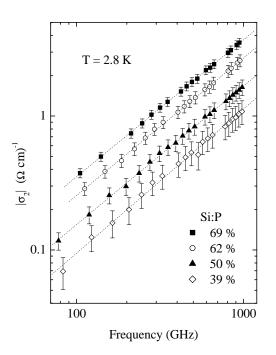


FIG.15. The low energy, linear in frequency magnitude of the imaginary part of the complex conductivity measured for four SiP samples plotted versus frequency. This data focuses on the C oulomb glass portion of electrodynamic response. The dashed lines are forced linear ts indicating self-consistency with the theory for a C oulomb glass, namely a linear frequency dependence and an increase in the magnitude of  $_2$  with increasing dopant concentration.

crossover in  $_1$  as a function of frequency. One might question whether this is physically acceptable on the grounds of K ram ers-K ronig (K K ) com patibility. This is established in Figure 16. This gure shows model data for 1, plotted as the dotted line, on an arbitrary conductivity axis that via proper utilization of the Heaviside function m in ics the Ferm i glass to Coulomb glasslike crossover, namely a change in the frequency dependence of the real part of the com plex conductivity from approxim ately linear to approxim ately quadratic, at the value of 10 on the arbitrary frequency scale. Above 100 on the arbitrary frequency scale a Lorentzian function is used to simulate a peak in the optical conductivity spectrum. The KK evaluated magnitude of 2, resulting from the model data of 1, is shown with the dashed curve. The imaginary component clearly displays a linear dependence on frequency, as evidenced by the shaded gray line, which is an aid to the eye for linear dependence, even though there exists an abrupt kink in the real part of the com plex conductivity.

Having established that below the crossover frequency, both components of the complex conductivity follow an approximately linear frequency dependence allows us to

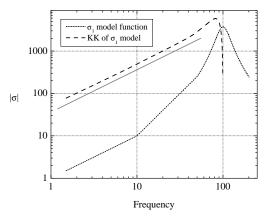


FIG. 16. A model function of  $_1$  (!), the dotted curve, and the K ram ers-K ronig calculated magnitude of  $_2$  (!), the dashed curve, on axes of arbitrary conductivity and frequency. The model function for  $_1$  (!) uses the H eaviside function to change from a linear dependence on frequency to a quadratic dependence at 10 on the arbitrary frequency scale. A bove 100 on the arbitrary frequency scale a Lorentzian function is used to simulate a peak in the optical conductivity spectrum. The shaded gray line indicates a linear dependence.

analyze the full com plex conductivity,  $\ \ ,$  using the follow ing K ram ers-K ronig com patible form ,

Such a dependence requires that the real and in aginary components follow the same power over a broad range of frequency and that this sim ple KK -com patible form only holds for 1, thus this is perfectly valid when analyzing the C oulom b glass regime. G iven the functional form of the complex conductivity in Equation (14), one can very accurately determ ine the power of by taking the ratio of the magnitude of  $_2$  and  $_1$  to obtain what is commonly known as the phase angle of the complex conductivity

$$= \frac{2}{-1} \tan^{-1} \frac{j_2 j}{1} :$$
 (15)

The ratio of  $j_2 \neq 1$  and the subsequent power of was determ ined for each of the SiP samples and the results are summarized in Figure 17. A similar analysis was performed on the insulating electron glass NbSi<sup>5</sup>, and the results from this Coulomb glass-like material are shown in the gure for comparison purposes. Panel (a) in Figure 17 shows the ratio of the magnitude of the imaginary to the real component of the complex conductivity for both SiP and NbSi.

It must be noted that the magnitude of the imaginary component plotted in the gure, for both SiP and NbSi, is that portion of the polarizability attributed to the interacting disordered electron system itself. Recall that

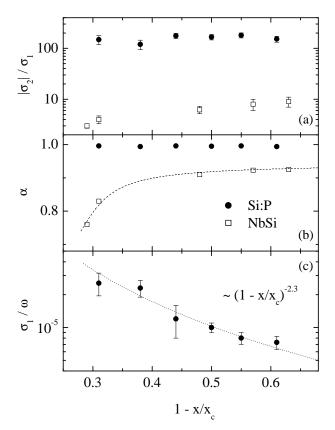


FIG.17. Panel (a) shows the ratio of them agnitude of  $_2$  to  $_1$  for the two C oulom b glasses m easured in this work, namely SiP and am orphous N bSi. Panel (b) shows the calculated powers of as determ ined from Equation (15). The dashed line through the N bSi data is a guide to the eye showing an approach to the value  $\frac{1}{2}$ , as expected upon approaching the quantum critical regime. Panel (c) shows the divergence of the m agnitude of  $_1$  as a function of concentration.

the experim entally determ ined quantity is the full dielectric constant, " $_1 = "_{S\,i} + 4$ . The imaginary component of the complex conductivity plotted in the gure has been calculated from the dielectric susceptibility portion 4 , resulting from the electron-electron interactions via the relationship  $j_2j/(4)$ !. The ratio of  $j_2 \neq 1$  using an imaginary component of the complex conductivity calculated from the full measured dielectric constant would necessarily diverge as the dopant concentration decreased, i.e. deep in the insulating regime, because  $j_2j$  would remain constant due to the static background dielectric constant from silicon itself, while  $_1$  would continuously decrease.

Returning to panel (a) in the gure, we rst note that this ratio for SiP remains large and approximately constant across our range of dopant concentrations. From theory, one expects  $j_1 j$  to be approximately equal to  $j_2 j$  to within a factor of 2-5 (with a reasonable estimate for  $I_0$ ) as predicted by E fros<sup>31</sup>. Applied to SiP, Eq. (12) in the h! < U (r<sub>!</sub>) lim it correctly predicts a linear correspondence between  $_1$  and  $j_2 j$ ; but the theory incorrectly predicts the measured proportionality by at least a factor of thirty. The proportionality is closer for NbSi but has a dependence on the doping concentration. This may be related to entering the quantum critical (QC) regime as discussed below. The magnitude of the ratio becomes even larger and the discrepancy greater if the full dielectric constant "1 is considered instead.

Panel (b) in Figure 17 show sthe power as determ ined by Eq. (15) for both the am orphous NbSi and SiP sam – ples. The values for SiP are approxim ately equal to, but slightly less than one, consistent with Figures 14 and 15. This indicates that the prefactor of the real and im aginary components of the com plex conductivity for our sam ples of SiP have the sam e concentration dependence across our entire range of dopant concentrations.

Panel (c) in Figure 17 shows the magnitude of the real part of the complex conductivity for the Sip sam ples as the MIT is approached from the insulating side. This demonstrates that the prefactor A as set forth in Equation (14) can be written as a function of the normalized concentration, i.e. A /  $(1 \frac{x}{x_c})$  for SiP. The prefactor of the im aginary component can be analyzed in a similar fashion and shows the same functional di- $\frac{x}{x_{c}}$ ) <sup>2:3</sup>. vergence as the real component, ie. (1 This indicates that the real and in aginary components have the same concentration dependence consistent with the simple K ram ers-K ronig form of the complex conductivity given in Equation (14). The fact that across a broad dopant range on the insulating side of the M IT we observe a similar divergence in both components of the complex conductivity for SiP is in accordance with the concentration dependent theoretical predictions for photon assisted hopping conductivity<sup>2</sup>, for excitations both within and larger than the Coulomb gap energy scale.

Still focussing on the C oulom b glass regime, the experin entally determ ined concentration dependence of the prefactor A, namely  $(1 \frac{x}{x_c})^{-2:3}$ , as shown in panel (c) of Figure 17, can be used to determ ine which theoretically predicted functional form for the real part of the com plex conductivity is more germ ane for our measured system. Recall that for photon energies smaller than the Coulom b gap width, i.e. excitations outside of the gap, the concentration dependent term s are sum m arized by the following:  $_1(!) = A! /$ !, and that for the alternate case, hopping conduction inside of the Coulom b gap one nds:  $_1(!) = A! / "_1!$ . Having experim entally determ ined a param eterization for the concentration dependencies for both the full dielectric conant, " $_1$  / (1  $\frac{x}{x_c}$ ) <sup>0:4</sup>, and the localization length, / (1  $\frac{x}{x_c}$ ) <sup>0:83</sup>, we nd that the functional form for stant, " $_{1}$  / (1 the prefactor is better described by photon-assisted hopping conduction occurring outside of the Coulomb gap. We nd that  $4="_1 / (1 \frac{x}{x_c})^{2:9}$ , which is not in exact agreem ent with our experimental ndings for the prefactor (and in fact the density of states, N<sub>0</sub> term would make this a slightly steeper function), but this is in m uch better agreem ent than the predicted concentration dependence of the prefactor for photon assisted hopping conduction inside the C oulom b gap.

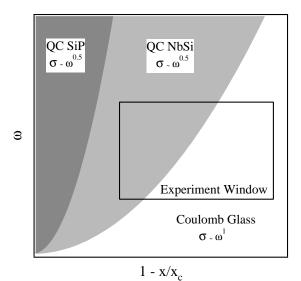


FIG.18. A schematic of a possible phase diagram indicating the relative positions of the crossover energy scale to QC behavior vs. concentration of SiP and NbSi. The solid box indicates the "window" from which our experimental results are derived.

## D.Quantum CriticalRegime

W hen approaching the M II from the insulating side, the frequency dependence is expected to cross over to the QC behavior<sup>6;32</sup>, i.e.  $_1 / !^{1=2}$  in NbSi, when the localization length becom es com parable to the characteristic frequency dependent length scale, the dephasing length,  $^{12}$ , as discussed in Section IIA. The crossover is not a phase transition and is not expected to be sharp. Therefore looking at a xed window of frequencies, a broad, smooth crossover from  $! ! !^{1=2}$  would show an averaged power of the frequency dependence sim ilar to that measured for NbSi shown in the middle panel of Figure 17. The fact that we see an 1 acrossourwhole doping range in SiP, but an that approaches  $\frac{1}{2}$  in NbSi indicates that the critical regime in SiP is much narrower. Simple dimensional arguments<sup>33</sup> give a result similar to the non-interacting case<sup>9</sup> that the crossover should be inversely proportional to the dopant DOS. The vastly smaller (a factor of 10<sup>3</sup>) dopant density in Sip relative to NbSi is consistent with a narrow erQC regime in SiP as com pared to NbSi.

A schematic outlining our experimental window and the boundaries for the crossover from the insulating Coulomb glass regime to the QC regime in both SiP and NbSiversus a normalized concentration is shown in F igure 18. The di erently shaded regions indicate the relative positions of the crossover energy scale to QC behavior for SiP and NbSi. A sm entioned above the crossover between the QC and the C oulomb glass regimes occurs when the localization length scale becomes comparable to the dephasing length scale, namely ?, and from this relationship one nds that the crossover frequency is inversely proportional to the DOS<sup>9</sup>. This crossover then is expected to be narrower in SiP as compared to NbSi due to its sm aller DOS. The crossover condition for the frequency in terms of the norm alized concentration is

$$!_{QC} / v_0^z = 1 - \frac{x}{x_c}^z$$
 (16)

where the subscript QC refers to the quantum critical regime. The functional dependence is expected to be universal but the prefactor can vary from system to system. This then de ness a condition for the crossover from QC to insulating glass-like behavior that depends only on the dynam ical scaling exponent, z, and the localization length exponent, , that is consistent with experimental evidence. For the case of z 2, and 1 as evidenced in NbS1<sup>6</sup> and SiP<sup>4</sup> respectively, the boundary would then have an approximately quadratic dependence on the norm alized concentration as shown in Figure 18.

## V.DISCUSSION

In analogy to the three phases of matter we are accustom ed to dealing with in elementary physics, the solid, liquid and gas phases, a collection or assembly of electrons can be classi ed in a similar manner depending on the electrodynam ic response of the system, each possessing an accompanying theoretical model. The room tem perature response of a metal upon applying an electric eld is well described by the D rude m odel. Here the electron system can be thought of as an electron gas with a tem perature dependent m ean free path and scattering time. An electron liquid would naturally be a system of electrons obeying Landau's theory of Ferm i liquids<sup>34;35</sup>. This successful theory has distinct hallmarks in the low energy lim it. W e shall investigate this low energy behavior m ore closely in the following section by comparing it to the low energy behavior of the materials we studied, generally classi ed as electron glasses.

The poorly understood and infrequently studied electron glassesm ight be considered a genre of the nalphase mentioned above, namely an electron solid, where the electronic states are localized due to disorder. The am orphous nature of the glassy state connotes disorder and hence this appellation was chosen to describe this type of assembly of electrons. V ia our unique and versatile A C conductivity measurement techniques, and by investigating a series of disordered insulating systems proxim al to a M IT, we have su cient experimental evidence for electron glass systems to propose a classi cation scheme, ie. a 'taxonom y' for the electrodynam ic response of electron glasses, along with a phase diagram containing appropriate crossover boundaries for the electron glass, C oulom b glass and quantum critical regimes.

## A.On the Nature of the Coulom b G lass

One of the fundam ental reasons for undertaking our investigations of these electron glasses is the surprising fact that even in a material as thoroughly studied as doped bulk silicon (due to the relevance of such research for the sem iconductor industry), there exists no clear consensus as to the ground state and the nature of the low energy excitations in these disordered insulating system s. Using the frequency dependent complex conductivity we wished to probe the question as to whether or not the Coulom b interactions fundam entally change the ground state of the system . A philosophy that persevered for many years was that in analogy to the Ferm i liquid theory, the theory describing the excitations at arbitrarily low energies in a system localized due to disorder, would indeed not be qualitatively in uenced by electron-electron interactions<sup>36</sup>. The theory created under this pretense was the one set forth by  $M \text{ ott}^1$ , which gives an approximately quadratic frequency dependence of the real component of the complex conductivity. The coining of the appellation Ferm i glass to describe this non-interacting disordered electron system was a direct consequence of the belief that there existed an analogy between the low energy electrodynam ics of a Ferm i liquid and this Ferm iglass. Later, theoretical work and subsequent investigations of the DC conductivity lent credence to the import of long range interactions stemming from negligible screening of the low energy excitations, e.g. the work by Pollak<sup>14;28</sup> and by E fros and Shklovskii<sup>2</sup>.

In 'm any' system s in solid state physics, this claim certainly is true, namely that the e ects of correlations becom e sim pler at low frequency or energy. The canonical example, as stated, is the Ferm i liquid. The heavyelectron compounds such as C eA la and U P ta are materials that have strongly correlated, yet delocalized charge carriers, and in the low energy lim it, they follow the noninteracting Ferm i liquid theory with renorm alized param eters such as the e ective m ass and the relaxation rate $^{37}$  . For these heavy-ferm ion system s there is a one to one correspondence between the low -lying excitations and those in a nearly free electron gas when the param eters of the latter, namely the mass and scattering rate, are properly renorm alized to take into account the correlations. The name 'heavy-electron' stems from this e ective enhanced m ass (often several hundred tim es) which is a direct consequence of the electron-electron interactions, but neverthe less the theory describing the electrodynam ic response of these system s is a non-interacting one.

On the other hand, our experimental data for both NbSi and SiP, two variants of electron glass systems,

show Coulomb glass-like behavior, i.e. a theory dependent on interactions, in the low energy frequency dependent electrodynam ic response. Experim ents done by another group on an electron glass system<sup>3</sup>, namely SiB, also show a linear in frequency power law dependence of the T = 0; ! ! 0 conductivity supporting and verifying the import of electron-electron interactions in the low-energy response of these disordered system s. W hile this work on SiB reported on only two concentrations of dopant very close to the M II, our further investigation across a broad range of dopant concentrations in Sip can con m that this linear power law dependence continues deep into the insulating regime. Thus we have clear evidence that an interacting theory, namely that of a Coulomb glass, dependent on electron-electron correlations, is correct at the low est experim entally accessible energy scales in these electron glass systems, in opposition to the original thoughts on the matter. Thus the Coulomb glass is a fundamental example in solid state physics as the non-interacting functional form is not recovered in the asymptotically low energy lim it.

#### B. The Taxonom y of an Electron G lass

Now we focus on the electron glass phase as a whole with the intent of setting forth a universal fram ework for the AC response of such disordered insulating systems. In summary, we have observed Coulomb glass-like behavior across our entire range of doping concentrations in Sip and via a comparison with NbSi have arrived at a boundary condition consistent with our experimental data for the crossover from QC to Coulom b glass-like behavior, namely Equation (16). We have also established that a crossover from Ferm iglass-like to Coulomb glasslike behavior exists, as is manifest in the experimental data of the real part of the complex frequency dependent conductivity, not only close to the M IT  $^3$ , but also deep into the insulating electron glass regime. Em ploying these phenom enological results, namely that the power laws seen in the frequency dependent complex conductivity are qualitatively consistent with the three expected types of frequency dependent behavior theoretically postulated for the electron glass regime, we propose that the real component of the frequency dependent complex conductivity of these disordered insulators can be param eterized in general by

$$_{1} / ! ^{(!;x)}$$
 (17)

where the power depends on the frequency and the dopant concentration. This classi cation scheme, or taxonomy, based on (!;x), captures the essential and germane physics of the electrodynamic response of electron glasses.

Figure 19 sum marizes our proposed phase diagram and taxonom y on a plot of frequency versus the normalized concentration  $(1 \quad \frac{x}{x_0})$ . Recall that the criterion for

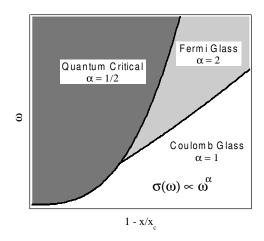


FIG.19. This schematic of a possible phase diagram for an electron glass shows the regime boundaries for the QC, the C oulom b glass and the Ferm i glass regimes in a two dimmensional space of frequency versus normalized concentration  $1 \quad \frac{x}{x_c}$ .

the regime boundary condition for the crossover from Coulom b glass or Ferm i glass-like behavior to the region where QC dynam ics dom inated was determ ined by Eq. (16). For a z = 2 theory and a localization length exponent = 1, this crossover would go as  $!_{qc}$  / (1  $\frac{x}{-})^{2}$ with a prefactor dependent on the dopant DOS. For the crossover from Fermiglass to Coulomb glass-like behavior, shown on the right hand side of the gure as the light gray and white regions respectively, we found that the crossover energy was more likely to be determ ined by the C oulom b interaction energy as opposed to the Coulomb gap width using concentration dependent argum ents. Either way our experim entally determ ined crossover had the following concentration dependence,  $\frac{x}{x}$ )<sup>1:65</sup>. Here we must note that though the !<sub>c</sub> / (1 curve depicting this latter crossover, as shown in the gure, m ight intersect the QC crossover curve (depending on the material's energy scales), the QC regime will always take precedence. Recall that this crossover energy stem s from a length scale argum ent that quantum critical behavior occurs when the electronic localization length,

, is greater than the dephasing length, i. Ergo since both the Ferm i glass and Coulom b glass behavior only occur in the opposite case, e.g. < i, the length scale dependent crossover condition for QC behavior always dictates the low energy, close to critical behavior.

The classi cation of the power of  $_1 / !$  <sup>(!</sup><sup>,x)</sup>, eg. = 1=2 for Q C dynamics, = 1 for C oulom b glass behavior and = 2 for Ferm iglass behavior, provides more than just a taxonom y for these disordered insulating system s. For the latter two regimes, with powers 1 and 2 respectively, these num bers also represent the dimensions of phase space changing directly as h! that these system s have access to for the creation of a real excitation.

## VI.CONCLUSION

In sum m ary, we have presented results of our frequency dependent com plex conductivity investigations into correlated electron phenom ena in the electrodynam ics of the electron glass SiP. The insulating side of the M II displayed the expected power law dependencies for a Ferm i glass and a Coulomb glass system with the latter being the low energy limit in our experimentally accessible window. In comparison with another electron glass, NbSi, with a distinctly di erent DOS, wherein we see a crossover from Coulomb glass-like behavior to quantum critical behavior, we have form ulated a phase diagram based on phenom enological observations of all the predicted states for the insulating side of the M IT . The taxonomy for the electron glass that we have presented, is an attempt to both capture the essence of the physics and allow for a general description of the low energy frequency dependent electrodynam ics of electron glasses.

A number of issues have also been left unresolved by this work. First of all, the apparent sharpness of the crossover in the realpart of the frequency dependent conductivity cannot be explained by the current model of E fros and Shklovskii<sup>2</sup>. Second, there certainly also exist furtherm isgivings with respect to the theories concerning the DC conductivity. For instance, the DC conductivity data does not seem to t the M ott or E S predictions particularly well for our doping levels well into the insulating phase as indicated by the unphysical characteristic tem peratures derived therefrom . A lso, we have experim entally observed a crossover energy in the DC conductivity that is quite comparable to the crossover energy seen in the frequency dependent conductivity, and there is no reason within the canonical theory that there should be a correspondence in the AC and DC energy scales. Thirdly the experim entally determ ined ratio of the im aginary to the real component of the complex conductivity shows a deviation from the predicted ratio. Should a subsequent re-analysis of the theories pertaining to the electrodynam ics of these electron glasses be undertaken, one should certainly include a self-consistent dynam ic dielectric constant, and in a correct description, the proper ratios and relative sharpness of the crossovers must be m anifest.

W e are also hopeful that this work will plant the seed for further future investigations of other disordered insulating system s. For instance the sam ples used in these investigations were nom inally uncom pensated. P urposeful com pensation will naturally redistribute m any relevant energy scales. It would be of fundam ental im portance to investigate the veracity of the proposed taxonom y of the electron glass with respect to com pensated system s. O ne m ust also note that our phase diagram stem m ed from phenom enological observations of the three types of electron glass behavior, nam ely Ferm i glass, C oulom b glass and quantum critical, but we would be rem iss if we neglected to em phasize that we did not physically observe a crossover from Ferm iglass to quantum critical behavior, just the other crossovers that are possible in the taxonom y phase diagram . Needless to say, such an observation would be of great in port in fully understanding electron glass behavior. Finally we have seen that in our experimentalwindow, the original expectations set forth in the literature<sup>36</sup> have proven to be not realized, in that at our low est accessible frequencies, an interacting theory is the germ ane one. This does not how ever rule out a subsequent change in the conduction mechanism at even low er frequencies, such as non-linear elects.

## VII.ACKNOW LEDGEMENTS

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